

Hall A

Section 1.



Fundamental processes in low-temperature plasma: low and high pressure discharges, near-electrode phenomena, radiation, ultrafast processes, diagnostics.

9.00-10.25	Oral Session (OS-1-5).	Chairman: <i>Ilya L. Muzyukin</i>
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1	Invited report 9.00-9.25	<p>OES of nitrogen atoms concentration during plasma processing <u><i>Svetlana V. Avtaeva</i></u> Institute of Laser Physics SB RAS, Novosibirsk, Russia</p>
2	Oral 9.25-9.45	<p>Spatial spectroscopy of magnetron discharge argon plasma using a radiative-collisional model <u><i>Sergey Serushkin</i></u> Bauman Moscow State Technical University, Moscow, Russia</p>
3	Oral 9.45-10.05	<p>OES investigation of a low-pressure non-self-sustained glow discharge plasma in Ar:N₂ gas mixture <u><i>Sergey S. Kovalsky, V.V. Denisov, E.V. Ostroverkhov, V.E. Prokop'ev</i></u> Institute of High Current Electronics SB RAS, Tomsk, Russia</p>
4	Oral 10.05-10.25	<p>Magnetic field influence on the penning discharge characteristics <u><i>Nikita V. Mamedov</i></u> <i>A.S. Rohmanenkov, A.A. Solodovnikov</i> Dukhov Automatics Research Institute, Moscow, Russia</p>

10.40-12.00	Oral Session (OS-1-6).	Chairman: <i>Dmitry A. Sorokin</i>
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1	Oral 10.40-11.05	<p>Methods for introducing negative feedback for beam current control in sources with a plasma cathode based on a low pressure arc</p> <p><i>Maxim Vorobyov, P. Moskvina, V. Devyatkov, N. Koval, V. Shin</i> Institute of High Current Electronics SB RAS, Tomsk, Russia</p>
2	Oral 11.05-11.30	<p>The problem of "anomalous" ion transport in high-current vacuum discharges</p> <p><i>V.Y. Kozhevnikov, Alexandr Kokovin, A.V. Kozyrev</i> Institute of High Current Electronics SB RAS, Tomsk, Russia</p>
3	Oral 11.30-11.55	<p>The measurements of vacuum arc behavior at threshold currents</p> <p><i>Ilya L. Muzyukin, P.S. Mikhailov</i> Institute of Electrophysics UB RAS, Ekaterinburg, Russia</p>

12.00-12.30	Closing Ceremony
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Hall B

Section 2.



Gas-discharge methods for surface modification and coating deposition: surface modification, ion implantation, combined methods of surface treatment.

09.00-10.25	Oral Session (OS-2-6).	Chairman: <i>Grey Sh. Boltachev</i>
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1	Invited report Online 9.00-9.35	Aerosol assisted atmospheric pressure plasma deposition for silver-containing antibacterial coatings <i>Lei Wang, C. Lo Porto, F. Palumbo, M. Modic, U. Cvelbar, C. Leys, A. Nikiforov</i> National University of Defense Technology, Changsha, China
2	Oral 9.35-10.00	Plasma modification of the surface of a steel product using the MAK-10 installation <i>S.A. Il'inyh, S.A. Ahmetshin, V.A. Krashaninin, Boris R. Gelchinski, A.A. Rempel</i> Institute of Metallurgy of the Ural Branch of the Russian Academy of Sciences, Ekaterinburg, Russia
3	Oral 10.00-10.25	Development of the computer model of the plasma installation <i>Roman A. Okulov, E.V. Popov, B.R. Gelchinski, A.A. Rempel</i> Institute of Metallurgy of the Ural Branch of the Russian Academy of Sciences, Ekaterinburg, Russia